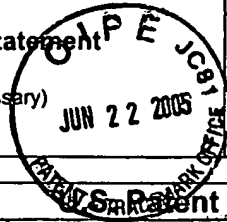


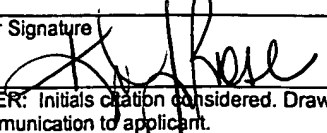
Substitute Form PTO-1449 (Modified)	U.S. Department of Commerce Patent and Trademark Office	Attorney's Docket No. 07977-024004	Application No. 10/713,275
Information Disclosure Statement by Applicant (Use several sheets if necessary) (37 CFR §1.98(b))		Applicant Isamu Kobori, et al.	
		Filing Date November 17, 2003	Group Art Unit 2822



Patent Documents							
Examiner Initial	Desig. ID	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
RR	AA	5,183,780	02/02/1993	Noguchi et al.			02/20/1991
	AB	5,341,012	08/23/1994	Misawa et al.			07/31/1992
	AC	5,396,084	03/07/1995	Matsumoto			06/02/1993
	AD	5,420,055	05/30/1995	Vu et al.			11/16/1993
	AE	5,466,617	11/14/1995	Shannon			06/15/1994
	AF	5,506,165	04/09/1996	Sato			03/15/1995
	AG	5,637,187	06/10/1997	Takasu et al.			06/05/1995
	AH	5,815,223	09/29/1998	Watanabe et al.			09/30/1997
	AI	5,932,484	08/03/1999	Iwanaga et al.			10/15/1997
KR	AJ	6,136,625	10/24/2000	Nakazawa			07/07/1998
	AK						

Foreign Patent Documents or Published Foreign Patent Applications								
Examiner Initial	Desig. ID	Document Number	Publication Date	Country or Patent Office	Class	Subclass	Translation	
							Yes	No
	AL							
	AM							
	AN							
	AO							
	AP							

Other Documents (include Author, Title, Date, and Place of Publication)		
Examiner Initial	Desig. ID	Document
	AQ	
	AR	
	AS	
	AT	

Examiner Signature 	Date Considered 9/15/05
EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	

11/17/05

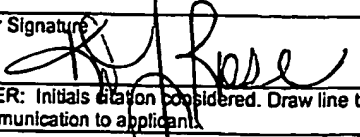
Sheet 1 of 2

Substitute Form PTO-1449 (Modified)	U.S. Department of Commerce Patent and Trademark Office	Attorney's Docket No. 07977-024004	Application No.
Information Disclosure Statement by Applicant (Use several sheets if necessary) (37 CFR §1.98(b))		Applicant Isamu Kobori et al.	
		Filing Date	Group Art Unit

U.S. Patent Documents							
Examiner Initial	Desig. ID	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
RR	AA	5,413,958	05/95	Imahashi, et al.			
	AB	5,529,630	06/96	Imahashi, et al.			
	AC	5,595,923	01/97	Zhang, et al.			
	AD	5,712,191	1/27/98	Nakajima, et al.			
	AE	5,731,613	3/24/98	Yamazaki, et al.			
	AF	5,767,930	06/98	Kobayashi, et al.			
	AG	5,854,494	05/95	Yamazaki, et al.			
	AH	5,854,096	12/98	Ohtani, et al.			
	AI	5,937,282	8/10/99	Nakajima, et al.			
	AJ	5,959,313	9/28/99	Yamazaki, et al.			
	AK	5,966,594	10/99	Adachi, et al.			
	AL	6,051,453	04/2000	Takemura			
RR	AM	6,071,764	06/2000	Zhang, et al.			
	AN						

Foreign Patent Documents or Published Foreign Patent Applications								
Examiner Initial	Desig. ID	Document Number	Publication Date	Country or Patent Office	Class	Subclass	Translation	
							Yes	No
RR	AO	05, 009,089 A	01/1993	Japan				
	AP	01-222432	09/05/89	Japan			ABS	
	AQ	06-260643	09/16/94	Japan			ABS	
	AR	2-150017	06/08/90	Japan			ABS	
	AS	2-224255	09/06/90	Japan			ABS	
	AT	6-84793	03/25/94	Japan			ABS	
RR	AU	6-124962	05/06/94	Japan			ABS	
	AV							

Other Documents (include Author, Title, Date, and Place of Publication)

Examiner Signature 	Date Considered 2/8/05 9/15/05
EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	

Substitute Form PTO-1449 (Modified)	U.S. Department of Commerce Patent and Trademark Office	Attorney's Docket No. 07977-024004	Application No.
Information Disclosure Statement by Applicant (Use several sheets if necessary) (37 CFR §1.98(b))		Applicant Isamu Kobori et al.	
		Filing Date	Group Art Unit

Examiner Initial	Desig. ID	Document
<i>kl</i>	AW	Y. Fukushima, et al., "A Poly-Si TFT Process for High Speed and Low Voltage CMOS Circuits", Extended Abstracts of the 1993 International Conference on Solid State Devices and Materials, Makuhari, pp. 993-995, 1993.
	AX	

Examiner Signature <i>[Signature]</i>	Date Considered <i>2/8/05</i> <i>9/15/05</i>
EXAMINER's initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	